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# Improved Remanent Supermirror Polarisers

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9<sup>th</sup> TECHNI Meeting  
The Cosener's House, Abingdon  
26. 02. 2004

design and manufacture of

– neutron focusing devices

simulations within SCANS

shifted to JRA3 “Neutron Optics”

– remanent neutron supermirror polarisers

reached:  $m = 3$ ,  $P \approx 97\%$

used at SINQ instruments and at FRM II

– self-supporting multilayer films

failed

provide beamtime and preparation facility for partners

has not been requested

(the upgrade of the sputtering plant led to delays)

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- high efficiency
- low absorption
- compact
- large bandwidth      allow for large divergence / 'white' beam
- switchable              no need for a spin flipper
- no magnetic fields      no interaction with sample (environment)
- non-deflecting          simpler lay-out

Material choice: Fe / Si

- contrast matching:  $\rho_{\text{Fe}}(b_{\text{Fe}} - p_{\text{Fe}}) \approx \rho_{\text{Si}}b_{\text{Si}}$   
 $\rho_{\text{Fe}}(b_{\text{Fe}} + p_{\text{Fe}}) \gg \rho_{\text{Si}}b_{\text{Si}}$
  - matching to the substrate
  - *rectangular* magnetic hysteresis
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magnetron sputtering (Leybold Z600)

conditions:

Fe in Ar

Si in Ar with N<sub>2</sub> and O<sub>2</sub> to

– match  $\rho_{\text{Fe}}(b_{\text{Fe}} - p_{\text{Fe}})$  and  $\rho_{\text{Si}}b_{\text{Si}}$

– decrease the overall stress



new *ansatz* (for us, not e.g. for T. Krist):

introduce a sollar slit for Fe

⇒ anisotropic deposition-angle distribution

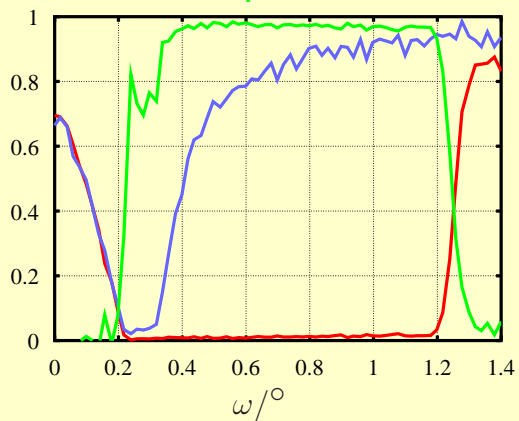
⇒ anisotropic stress

⇒ no O<sub>2</sub> for Si

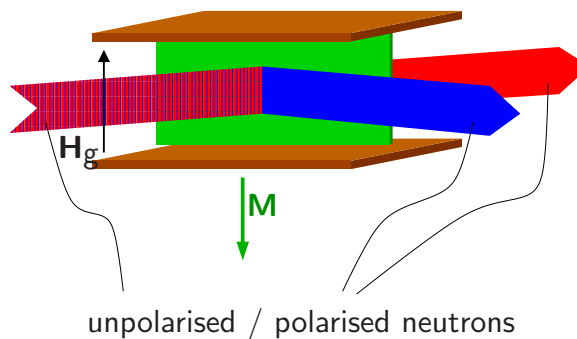
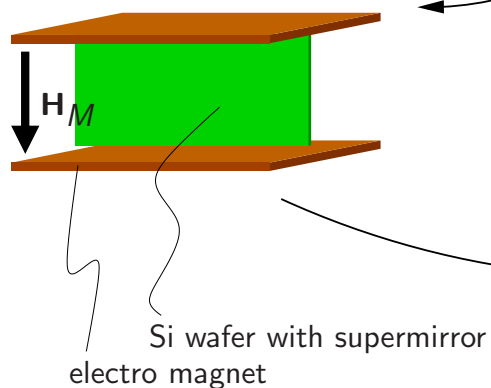
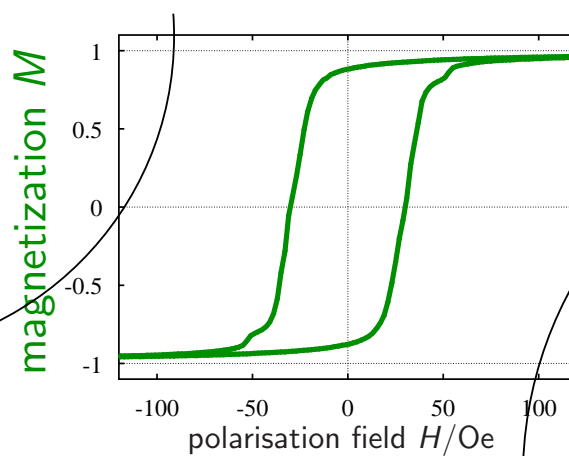
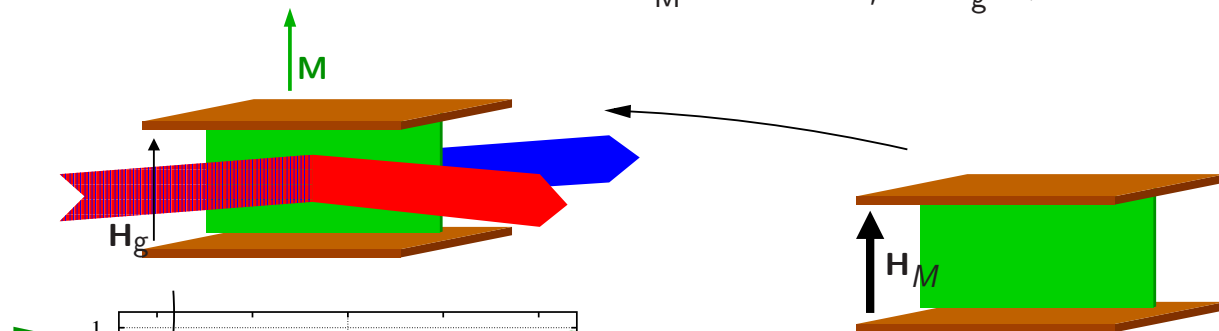


# Application principle

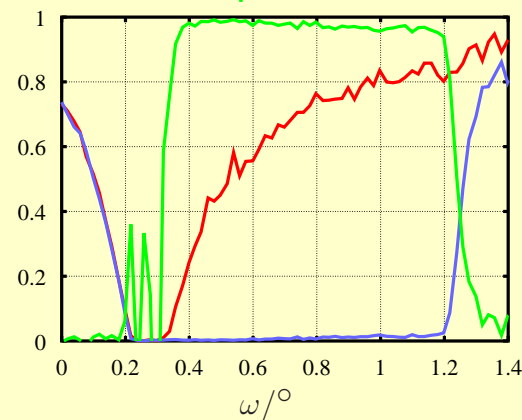
transmission, polarisation



$H_M \approx 150$  Oe,  $H_g < 30$  Oe



transmission, polarisation



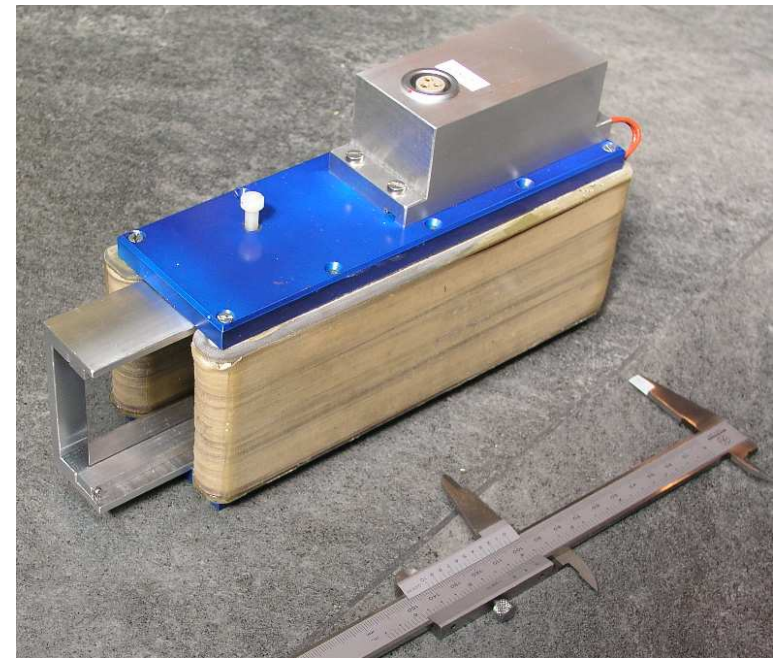
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# Compact transmission analyser

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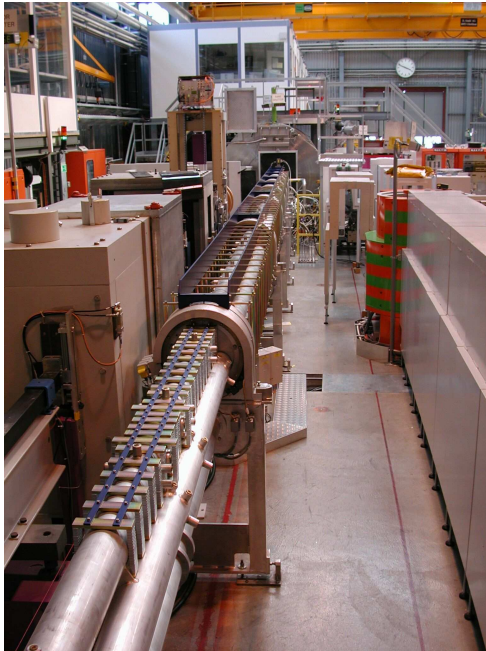
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coating	Fe / Si:N:O
	$m = 3, 599$ layers
substrate	Si-wafer, 0.6 mm
mirror size	$200 \times 60 \text{ mm}^2$
magnet size	$200 \times 100 \times 100 \text{ mm}^3$
$B_M$	200 Oe
$B_g$	20 Oe
$P_{T, \uparrow\uparrow}$	$> 97 \%$
$P_{T, \uparrow\downarrow}$	$> 95 \%$

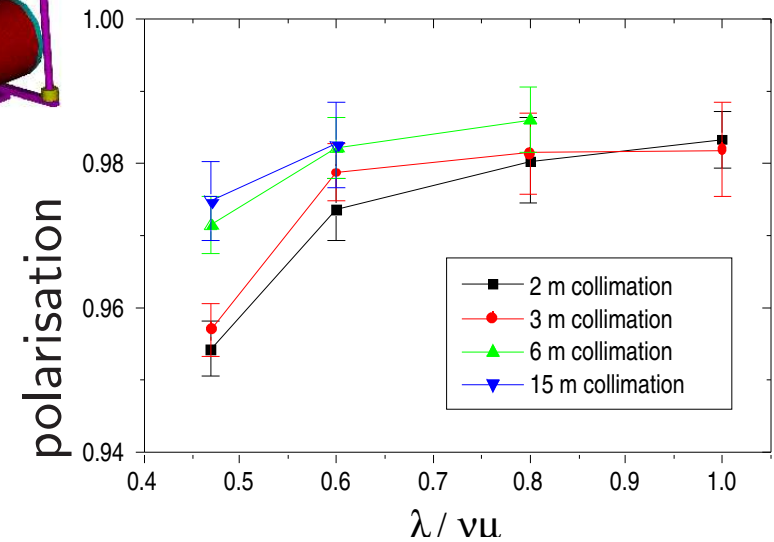
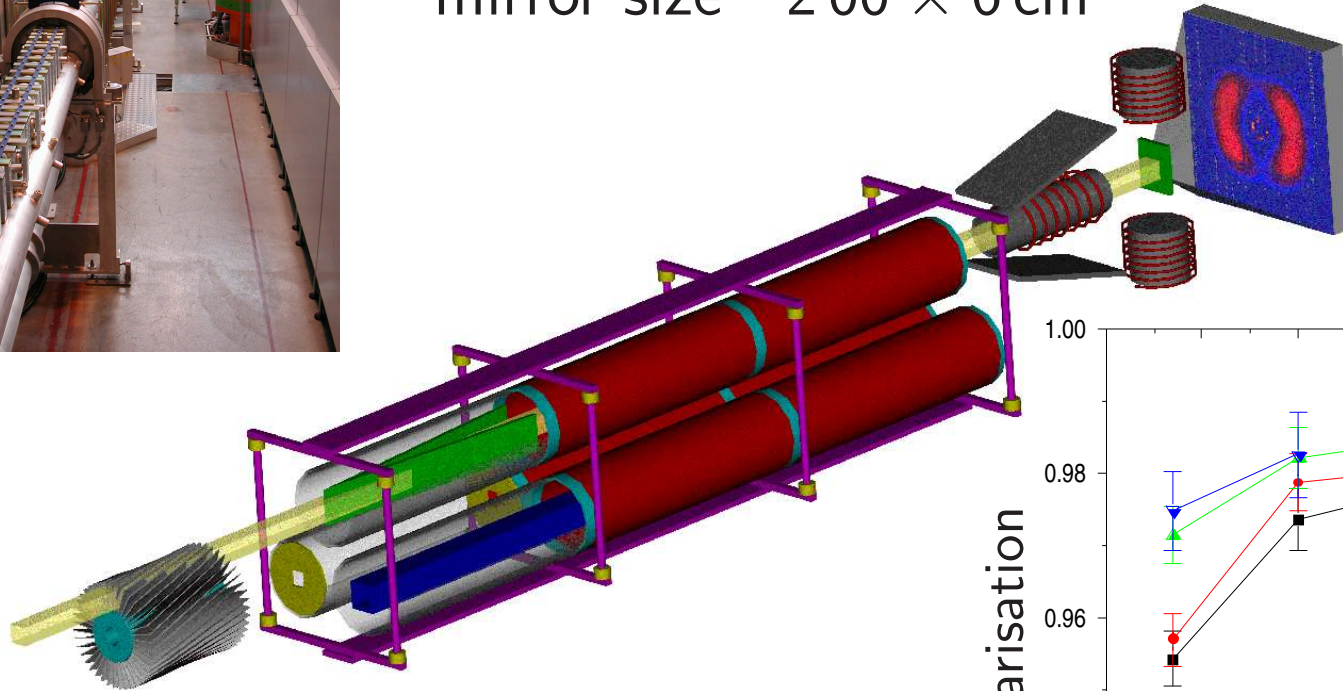


# Transmission polariser at SANS-I @ SINQ

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coating Fe / Si:N:O  
 $m = 2.4$ , 299 layers  
substrate Si-wafer, 0.6 mm  
mirror size  $200 \times 6 \text{ cm}^2$



. . . in the field of neutron supermirrors:

- remanent polariser
    - aim for  $q > 3$
    - build compact switchable device with bent supermirrors
    - tune remanence by changing sputter geometry
  - multilayers with non-sharp interfaces (J. Padiyath)
  - laterally graded multilayers for focusing optics (JRA3-NO)
  - build (scaled) prototypes to check MC simulation predictions on elliptic and parabolic guides
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